



IPW

## PATENT

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Katie Hales  
Katie Hales

### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 10/715,758

Attorney Docket: DP-302242 DIV

Filing Date: 11/18/2003

Group Art Unit: 1763

Applicant: David B. Rich et al.

Examiner: Kwok, Helen C.

Title: DEEP REACTIVE INO ETCHING PROCESS AND  
MICROELECTROMECHANICAL DEVICES FORMED THEREBY

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MS Fee/Non-Fee Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

### AMENDMENT

Sir:

In response to the Office Action mailed November 22, 2005, please amend the subject application and consider the remarks set forth herein.

I. Amendment to the Claims

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II. Remarks

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